

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	455	oxide and (chamber same cleaning) and halogen and chamber adj walls	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/02 12:00
S2	136	load adj lock and S1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/03 12:49
S3	2	("6066519").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/03/03 12:11
S4	455	oxide and (chamber same cleaning) and halogen and chamber adj walls	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/03 14:00
S5	7	load adj lock and S4 and second adj temperature	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/03 12:50
S6	28	implanting near4 room adj temperature	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/03 13:35
S7	27	cluster adj tool and mosfet and room adj temperature	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/03 13:35
S8	281	oxide and (chamber same cleaning) and halogen and chamber adj walls and ceramic	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/03 14:31

S9	415396	oxide same temperature	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/03 14:31
S10	156	S8 and S9	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/04 10:17
S11	84575	temperature near5 oxide	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/03 14:32
S12	76	S10 and S11	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/03 14:32
S13	5	("5186718" "5254176" "5286296" "5308431" "5380370").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/04 09:58
S14	363226	heater and "5"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/04 09:58
S15	2	heater and S13	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/04 09:59
S16	26	substrate adj heater near4 embedded	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/04 09:59
S17	281	oxide and (chamber same cleaning) and halogen and chamber adj walls and ceramic	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/04 10:17

S18	415591	oxide same temperature	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/04 10:17
S19	156	S17 and S18	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/04 10:18
S20	17	teos and (psg or phosphorus adj doped glass) and S19	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/03/04 10:18
S21	888	(438/404).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/02 12:11
S22	34	((insulation or insulative or oxide) and second adj temperature and halogen).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/02 12:12